

PROCESS FOR DEPOSITING BTBAS-BASED SILICON NITRIDE FILMS

Appl. No. : 10/711,414 Confirmation No. 5413
Applicant : Yun-Ren Wang,
Ying-Wei Yen,
Hao-Hsiang Chang,
Tsai-Fu Hsiao
Filed : September 17, 2004
TC/A.U. : 1709
Examiner : MILLER, MICHAEL G
Docket No. : NAUP0594USA
Customer No. : 27765

Commissioner for Patents
P.O. Box 1450
Alexandria VA 22313-1450

AMENDMENT

Sir:

5 In response to the Office action of June 29, 2007, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Amendments to the Drawings begin on page 4 of this paper and include an attached replacement sheet showing changes.

10 **Remarks/Arguments** begin on page 5 of this paper.

An **Appendix** including the amended drawing figure is attached following page 9 of this paper.